## IN THE SPECIFICATION:

Page 1, below the title, please update the first paragraph of the specification with the following correction:

## RELATED APPLICATIONS

[0001] This application is a Continuation-In-Part of United States Patent
Application Serial No. 10/361,831, filed on February 11, 2003, now U.S. Patent No.
6.839,125, entitled "Method for Optimizing an Illumination Source Using Full Resist
Simulation and Process Window Metric", the content of which is incorporated herein in its
entirety by reference.